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(12) **United States Design Patent**
Cailleret et al.

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(54) **FABRIC DESIGN IN RELIEF**

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(**) Term: **14 Years**

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(51) **LOC (9) Cl.** **05-02**

(52) **U.S. Cl.** **D5/47**

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D5/26, 27, 30, 32, 35, 36, 37, 39, 40, 41,
D5/44, 45, 46, 47, 49, 50, 52-64, 99; D6/596,
D6/598, 603, 604, 605, 606, 608, 613, 617,
D6/619, 622; 52/581; 256/73; D32/40;
66/193; D2/749, 994; 428/17, 18, 151, 154,
428/156, 171, 187, 198, 199, 904.4, 542.2,
428/919, 542.6; D24/125

See application file for complete search history.

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(57) **CLAIM**

The ornamental design for a fabric design in relief, as shown
and described.

DESCRIPTION

FIG. 1 is a plan view of our new design; and,
FIG. 2 is a front, enlarged, partial perspective view taken from
the perspective 2-2 as indicated on FIG. 1.

1 Claim, 2 Drawing Sheets

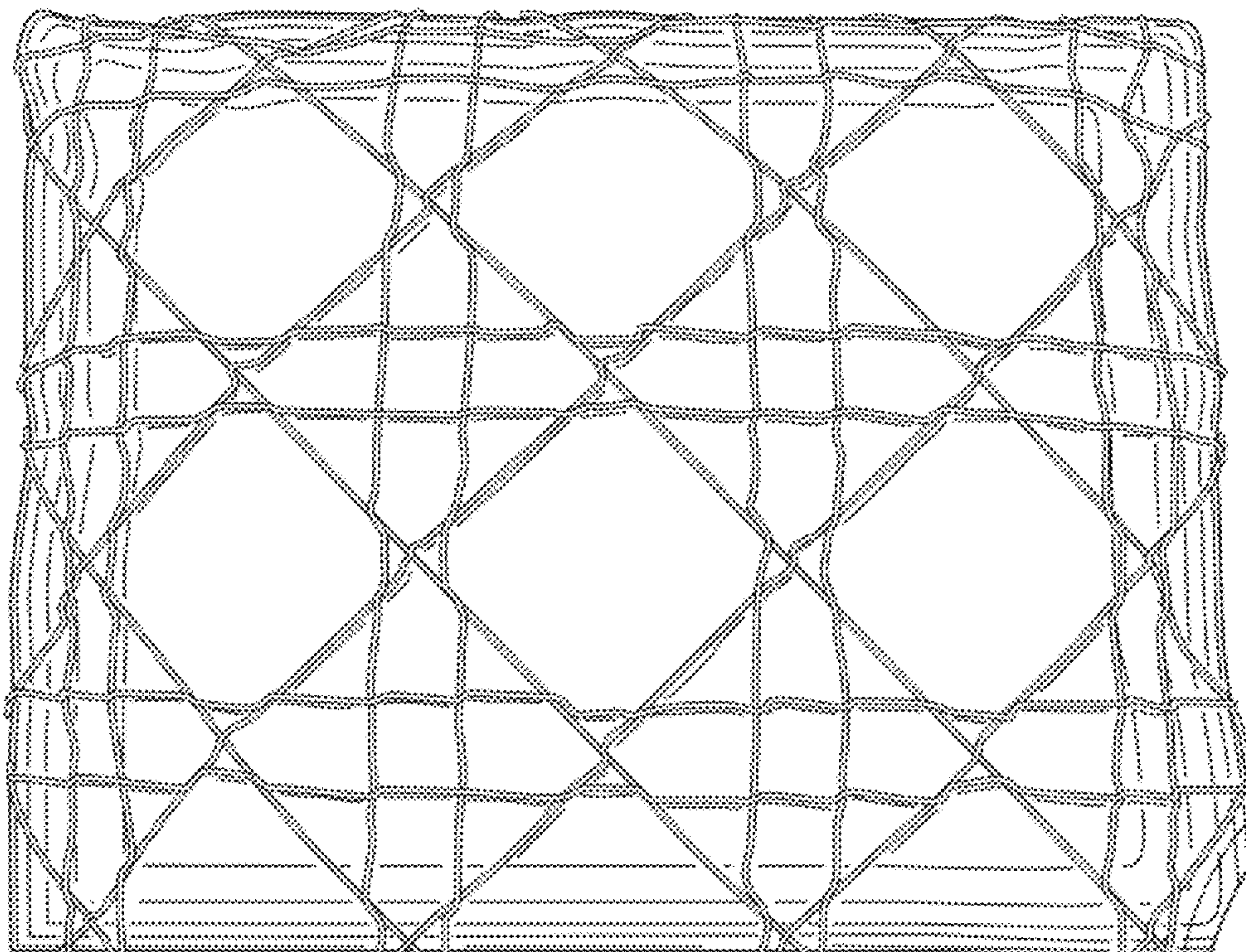


FIG. 1

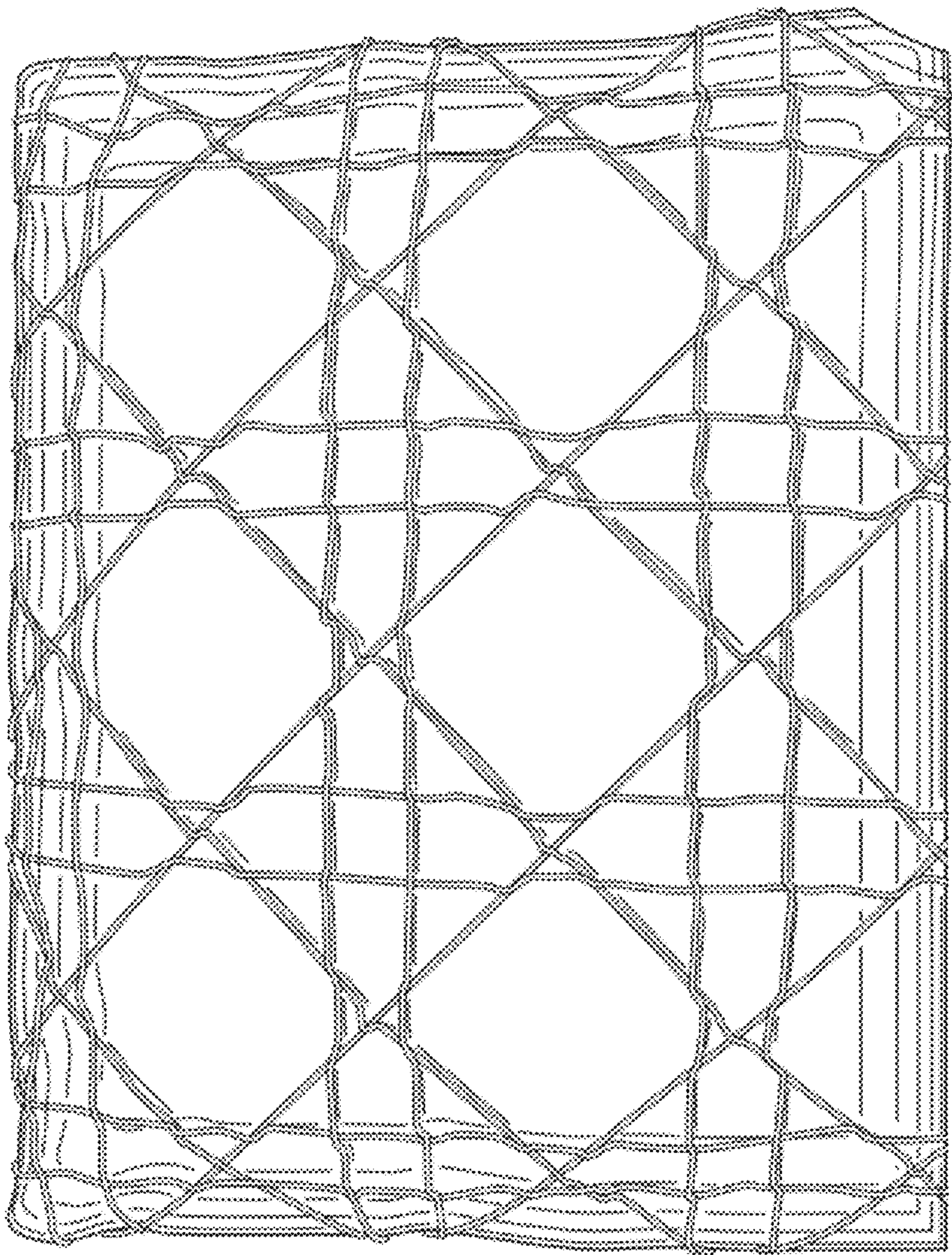


FIG. 2

